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## LIST OF PRIOR ART CITED BY APPLICANT

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Docket No. **GK-OEH-217/500814.20119**Applicant(s): **Juergen WEISSER, Stefan ACKER and Ronny ULLMANN**

Application No. (Int'l Appln No. PCT/DE2004/00149002JULN04) Group:

Filed: Examiner:

## U.S. PATENT DOCUMENTS

Exam. Init		Document Number	Date	Name	Class	Sub-Class	Filing Date Appropriate
	AA	6,023,039	02/08/2000	Sawada			
	AB	6,327,875	12/11/2001	Allaire, et al.			
	AC	6,420,678	07/16/2002	Hoekstra			
	AD	2001/0035447	11/01/2001	Gartner, et al.			
	AE	2003/0024909	02/06/2003	Hoekstra, et al.			
	AF						
	AG						
	AH						
	AI						

## FOREIGN PATENT DOCUMENTS

		Document Number	Date	Country	CLASS	Sub-Class	Translation YES	NO
	AL	1 244 346	07/13/1967	Germany			US 3,453,097	
	AM	1231813	04/23/1991	Soviet Union			(not available)	
	AN	0 448 168	09/25/1991	European			n/a	
	AO	WO 93/20015	10/14/1993	WIPO			Abstract only	
	AP	WO 96/20062	07/04/1996	WIPO			Abstract only	
	AQ	0 872 303	10/21/1998	European			US 6,112,967	
	AR	199 55 824	06/13/2001	Germany			Abstract only	
	AS	100 41 519	11/22/2001	Germany			Abstract only	
	AT	WO 02/48059	07/20/2002	WIPO			Abstract only	
	AU	WO 04/060823	07/22/2004	WIPO			Abstract only	

## OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)

	AW	XP-002305390 SU-66143 06/08/1979 "SHEET GLASS CUT CONTROL SYSTEM THERMO ELASTIC STRESS SENSE POLARIMETER CONNECT ADDER RESIDUE STRESS CALCULATE"
	AX	XP-002305391 SU-1308573 05/07/1987 "CUT GLASS STRIP SMOOTH WAVE SURFACE VARY FORCE CUT TOOL PROPORTION INCREASE STRESS GLASS"
	AY	Patent Abstracts of Japan, Publication No. 01167248 06/30/1989, Central Glass Co Ltd. "METHOD FOR CUTTING GLASS ARTICLE"
	AZ	Patent Abstracts of Japan, Publication No.10116801 05/06/1998, Rohn Co Ltd., "METHOD FOR DIVIDING SUBSTRATE AND MANUFACTURE OF LIGHT EMITTING ELEMENT USING THE METHOD"

Examiner: /Hung Nguyen/

Date: 01/30/2009

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /H.N./